

# ABSTRACT

There is provided an excimer laser device capable of producing a stable oscillation  
5 even at a high repetition rate of 4 kHz. This gas laser device is comprised of a laser chamber  
having laser gas filled therein; a pair of main discharge electrodes arranged in the laser cham-  
ber; a cross-flow fan for circulating the laser gas within the laser chamber at least between the  
main discharge electrodes; and a diameter of the cross-flow fan is 150 mm or less, its periph-  
eral speed being 25.0 m/s or more.

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